

## Analysis of Co<sub>3</sub>O<sub>4</sub>-SnO<sub>2</sub> and Co<sub>3</sub>O<sub>4</sub>-Fe<sub>2</sub>O<sub>3</sub> nanosystems by X-ray photoelectron spectroscopy

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In this work, X-ray photoelectron spectroscopy (XPS) was employed to characterize the surface composition and elemental chemical states of supported Co<sub>3</sub>O<sub>4</sub>-SnO<sub>2</sub> and Co<sub>3</sub>O<sub>4</sub>-Fe<sub>2</sub>O<sub>3</sub> nanocomposites. The present materials were prepared on Si(100) substrates by the chemical vapor deposition (CVD) of cobalt oxide under O<sub>2</sub>+H<sub>2</sub>O atmospheres, followed by the tailored introduction of SnO<sub>2</sub> or Fe<sub>2</sub>O<sub>3</sub> by means of radio frequency (RF)-sputtering. Material structural and morphological characterization revealed the formation of nanocomposite heterostructures involving a conformal Co<sub>3</sub>O<sub>4</sub> coverage by SnO<sub>2</sub> or Fe<sub>2</sub>O<sub>3</sub> overlayers. Survey spectra, as well as detailed scans of C1s, O1s, Co2p, Sn3d and Fe2p regions are presented and critically discussed. The results provide evidence for the formation of pure and oxygen-deficient nanocomposites, and the occurrence of an electronic interplay between the single oxide constituents.

**Keywords:** Co<sub>3</sub>O<sub>4</sub>; SnO<sub>2</sub>; Fe<sub>2</sub>O<sub>3</sub>; CVD; RF-sputtering; X-ray photoelectron spectroscopy

### INTRODUCTION

Among metal oxides, cobalt oxide (Co<sub>3</sub>O<sub>4</sub>), a versatile *p*-type semiconductor endowed with a band gap enabling to efficiently harvest visible light, has received attention as an attractive material for different (photo)catalytic applications (Refs. 1-9). Nevertheless, to the best of our knowledge, no works focusing on Co<sub>3</sub>O<sub>4</sub>-based materials as photocatalysts for the removal of atmospheric nitrogen oxides (De-NO<sub>x</sub>) are available in the literature up to date. Indeed, this kind of technological application has been the focus of an ever growing interest for the protection of both environment and human health, since nitrogen monoxide (NO) can yield various problems including photochemical smog, acid rains, and ozone depletion, detrimentally affecting people health even at low concentrations (Refs. 3, 10-14). These issues, along with the high toxicity even of nitrogen dioxide (NO<sub>2</sub>), have stimulated research efforts aimed at the fabrication of efficient and stable solar-active photocatalysts for air purification, especially in urban/industrialized areas (Refs. 15-17). In this regard, a key requirement is the obtainment of an enhanced selectivity towards the formation of harmless nitrate species as the main products (Refs. 15, 16, 18).

In our research group, the attention has been dedicated to the design and preparation of supported oxide nanosystems as De-NO<sub>x</sub> photocatalysts, which are more promising than the conventionally studied powdered homologues thanks to their higher stability upon prolonged operation and easier recovery after use (Refs. 12, 19, 20). In this context, recent research activities have been focused on De-NO<sub>x</sub> photocatalysts based on Co<sub>3</sub>O<sub>4</sub> nanomaterials obtained by chemical vapor deposition (CVD), an attractive route for the preparation of supported materials with tailored properties (Ref. 14). Furthermore, we have explored the influence of Co<sub>3</sub>O<sub>4</sub> functionalization with SnO<sub>2</sub> or Fe<sub>2</sub>O<sub>3</sub> for a possible tailoring of the ultimate system photoactivity. Whereas SnO<sub>2</sub>, exploited as environmental photocatalyst in

combination with Co<sub>3</sub>O<sub>4</sub> (Refs. 7, 21), possesses matched band potentials with Co<sub>3</sub>O<sub>4</sub> ones to yield an improved separation of photogenerated charge carriers (Ref. 22), Fe<sub>2</sub>O<sub>3</sub> yields a promising photocatalytic activity in various processes (Refs. 14, 20, 23, 24). Following our previous studies on the fabrication of metal oxide composites (Refs. 1, 19, 20, 25), SnO<sub>2</sub> or Fe<sub>2</sub>O<sub>3</sub> deposition on Co<sub>3</sub>O<sub>4</sub> was carried out by radio frequency (RF)-sputtering under mild conditions. In this context, the present contribution is dedicated to the room temperature X-ray photoelectron spectroscopy (XPS) analysis, performed using a standard Mg K $\alpha$  X-ray source, of Co<sub>3</sub>O<sub>4</sub>-SnO<sub>2</sub> and Co<sub>3</sub>O<sub>4</sub>-Fe<sub>2</sub>O<sub>3</sub> nanomaterials on Si substrates. The attention was devoted to the analysis of C1s, O1s, Co2p, Sn3d and Fe2p core levels, with particular regard to the chemical states of the different elements and to the interplay between the components of the developed nanocomposites. The latter, with specific reference to electronic interactions, directly influences the ultimate material activity in photocatalytic De-NO<sub>x</sub> applications. The results of this investigation can pave the way to future research developments on the tailored engineering of oxide-oxide interfaces for the production of improved environmental photocatalysts.

### SPECIMEN DESCRIPTION (ACCESSION # 00000)

**Host Material:** Co<sub>3</sub>O<sub>4</sub>-SnO<sub>2</sub>

**CAS Registry #:** unknown

**Host Material Characteristics:** homogeneous; solid; polycrystalline; semiconductor; composite; Thin Film

**Chemical Name:** Cobalt (II,III) oxide – tin (IV) oxide

**Source:** specimen deposited on Si(100) by CVD of Co<sub>3</sub>O<sub>4</sub> and subsequently functionalized with SnO<sub>2</sub> by RF-sputtering

**Host Composition:** Co, O, Sn

**Accession#:** Enter  
Accession Number.

**Technique:** XPS

**Host Material:** Co<sub>3</sub>O<sub>4</sub>-  
SnO<sub>2</sub>; Co<sub>3</sub>O<sub>4</sub>-Fe<sub>2</sub>O<sub>3</sub>

**Instrument:** Perkin-Elmer  
Physical Electronics, Inc.  
5600ci

**Major Elements in  
Spectra:** C, O, Co, Sn, Fe

**Minor Elements in  
Spectra:** none

**Published Spectra:** 10

**Spectra in Electronic  
Record:** 10

**Spectral Category:**  
comparison

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**Form:** Supported nanocomposite thin film

**Structure:** The system structure was preliminarily investigated by X-ray diffraction (XRD) analyses, which provided evidence for the presence of a single peak at  $2\theta = 36.9^\circ$ , corresponding to (311) crystallographic planes of cubic  $\text{Co}_3\text{O}_4$  (Ref. 26). The lack of appreciable peaks related to crystalline  $\text{SnO}_2$  or mixed Co-Sn-O phases was related to the low  $\text{SnO}_2$  loading (Refs. 25). Field emission-scanning electron microscopy (FE-SEM) analyses (see inset in figure # NFigA01) highlighted the occurrence of uniformly distributed columnar nanostructures (mean width = 50 nm; mean length = 930 nm), grown perpendicularly to the substrate surface. Transmission electron microscopy (TEM) data revealed a conformal coverage of  $\text{Co}_3\text{O}_4$  aggregates by a partially continuous, amorphous  $\text{SnO}_2$  overlayer, whose very low thickness (a few nm) prevented its clear observation by FE-SEM analyses.

**History & Significance:** The used cobalt molecular precursor,  $\text{Co}(\text{tfa})_2 \cdot \text{TMEDA}$  ( $\text{htfa} = 1,1,1$ -trifluoro-2,4-pentanedione;  $\text{TMEDA} = N,N,N',N'$ -tetramethylethylenediamine), was prepared by reacting the ligands with  $\text{Co}(\text{II})$  chloride in alkaline aqueous solution.  $\text{Co}_3\text{O}_4$  deposition was performed by CVD using a home-made, cold-wall horizontal CVD apparatus.  $\text{Si}(100)$  substrates (MEMC<sup>®</sup>, Merano, Italy) were pre-cleaned by sonication in *i*-PrOH and  $\text{CH}_2\text{Cl}_2$ , and subsequently etched in a 2% HF solution in order to remove the native  $\text{SiO}_2$  film. Growth processes were performed at  $400^\circ\text{C}$  for 2 h, using a total pressure of 10.0 mbar. The precursor was heated at  $70^\circ\text{C}$  in an external reservoir located in an oil bath, and its vapors were transported into the reaction chamber through heated gas lines by means of an electronic grade  $\text{O}_2$  flow [rate = 100 standard cubic centimeters per minute (sccm)]. An additional  $\text{O}_2$  flow (rate = 100 sccm) was delivered into the reactor through a separate inlet, after passing through a  $\text{H}_2\text{O}$  reservoir maintained at  $35^\circ\text{C}$ . Functionalization with  $\text{SnO}_2$  was accomplished by RF-sputtering from Ar plasmas using a home-made two-electrode plasmochemical reactor ( $\nu = 13.56$  MHz). A tin target (Neyco<sup>®</sup>; purity = 99.99%; diameter = 5 cm; thickness = 2.0 mm) was fixed on the RF electrode, whereas  $\text{Si}$ -supported  $\text{Co}_3\text{O}_4$  was mounted on the grounded one. Depositions were performed at  $60^\circ\text{C}$  for 90 min, using a RF-power of 10 W, an electronic grade Ar flow rate of 10 sccm, and a total pressure of 1.0 mbar.

**As Received Condition:** as grown

**Analyzed Region:** same as host material

**Ex Situ Preparation/Mounting:** Sample fixed on a grounded sample holder and introduced into the analysis chamber through a fast entry lock system.

**In Situ Preparation:** none

**Charge Control:** No flood gun was used during analysis.

**Temp. During Analysis:** 298 K

**Pressure During Analysis:**  $<10^{-8}$  Pa

**Pre-analysis Beam Exposure:** 180 s.

### **SPECIMEN DESCRIPTION (ACCESSION # 00000)**

**Host Material:**  $\text{Co}_3\text{O}_4$ - $\text{Fe}_2\text{O}_3$

**CAS Registry #:** unknown

**Host Material Characteristics:** homogeneous; solid; polycrystalline; semiconductor; composite; Thin Film

**Chemical Name:** Cobalt (II,III) oxide – iron (III) oxide

**Source:** specimen deposited on  $\text{Si}(100)$  by CVD of  $\text{Co}_3\text{O}_4$  and subsequently functionalized with  $\text{Fe}_2\text{O}_3$  by RF-sputtering

**Host Composition:** Co, O, Fe

**Form:** Supported nanocomposite thin film

**Structure:** The sample XRD pattern was very similar to that of  $\text{Co}_3\text{O}_4$ - $\text{SnO}_2$  (see the previous accession). In line with these observations, FE-SEM analyses (see inset in figure # NFigB01) showed no appreciable morphological variations with respect to the previous specimen, and TEM results evidenced a uniform and very thin ( $\approx 1$  nm)  $\text{Fe}_2\text{O}_3$  layer over the  $\text{Co}_3\text{O}_4$  deposit, whose structure corresponded to that of  $\gamma$ - $\text{Fe}_2\text{O}_3$  (Ref. 27).

**History & Significance:** CVD of  $\text{Co}_3\text{O}_4$  was performed using the same pre-cleaned  $\text{Si}(100)$  substrate and experimental conditions reported for the previous accession. Functionalization with  $\text{Fe}_2\text{O}_3$  was performed by RF-sputtering starting from an iron target (Alfa Aesar<sup>®</sup>; purity = 99.995%;  $5 \times 5$  cm<sup>2</sup>; thickness = 0.25 mm), using the same plasmochemical apparatus and operating conditions reported from the previous specimen. The only exceptions were the RF-power and sputtering time values, which were set at 20 W and 180 min, respectively.

**As Received Condition:** as grown

**Analyzed Region:** same as host material

**Ex Situ Preparation/Mounting:** Sample fixed on a grounded sample holder and introduced into the analysis chamber through a fast entry lock system.

**In Situ Preparation:** none

**Charge Control:** No flood gun was used during analysis.

**Temp. During Analysis:** 298 K

**Pressure During Analysis:**  $<10^{-8}$  Pa

**Pre-analysis Beam Exposure:** 180 s.

### **INSTRUMENT DESCRIPTION**

**Manufacturer and Model:** Perkin-Elmer Physical Electronics, Inc. 5600ci

**Analyzer Type:** spherical sector

**Detector:** Channeltron

**Number of Detector Elements:** 16

### **INSTRUMENT PARAMETERS COMMON TO ALL SPECTRA**

#### ■ Spectrometer

**Analyzer Mode:** constant pass energy

**Throughput ( $T=E^N$ ):**  $N=0$

**Excitation Source Window:** 1.5 micron Al window

**Excitation Source:** Mg Ka

**Source Energy:** 1253.6 eV

**Source Strength:** 250 W

**Source Beam Size:**  $> 25000 \mu\text{m} \times > 25000 \mu\text{m}$

**Signal Mode:** multichannel direct

#### ■ Geometry

**Incident Angle:**  $9^\circ$

**Source-to-Analyzer Angle:** 53.8°  
**Emission Angle:** 45°  
**Specimen Azimuthal Angle:** 0°  
**Acceptance Angle from Analyzer Axis:** 0°  
**Analyzer Angular Acceptance Width:** 14° × 14°

#### ■ Ion Gun

**Manufacturer and Model:** PHI 04-303 A  
**Energy:** 4000 eV  
**Current:** 0.4 mA/cm<sup>2</sup>  
**Current Measurement Method:** Faraday cup  
**Sputtering Species:** Ar<sup>+</sup>  
**Spot Size (unrastered):** 250 μm  
**Raster Size:** 2000 μm × 2000 μm  
**Incident Angle:** 40°  
**Polar Angle:** 45°  
**Azimuthal Angle:** 111°  
**Comment:** differentially pumped ion gun

#### DATA ANALYSIS METHOD

**Energy Scale Correction:** -  
**Recommended Energy Scale Shift:** 0 eV for both specimens  
**Peak Shape and Background Method:** After performing a Shirley-type background subtraction (Ref. 28), BE and full width at half maximum (FWHM) values were determined by least-squares fitting adopting Gaussian/Lorentzian functions.  
**Quantitation Method:** Atomic concentrations were calculated by peak area integration, using sensitivity factors provided by PHI V5.4A software.

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Spectrum ID #	Element/Transition	Peak Energy (eV)	Peak Width FWHM (eV)	Peak Area (eV x cts/s)	Sensitivity Factor	Concentration (at. %)	Peak Assignment
NFigA02 <sup>a</sup>	C1s	284.8	1.7	9546.4	0.296	20.7	Adventitious surface contamination
NFigA02 <sup>a</sup>	C1s	286.3	2.0	2365.1	0.296	5.1	C-O species from precursor residuals
NFigA02 <sup>a</sup>	C1s	288.5	2.3	1044.5	0.296	2.3	Adsorbed carbonates
NFigA03 <sup>b</sup>	O1s	530.1	1.9	33452.4	0.711	29.6	Lattice oxygen in Co <sub>3</sub> O <sub>4</sub> and SnO <sub>2</sub>
NFigA03 <sup>b</sup>	O1s	531.4	2.1	20329.0	0.711	18.1	Surface adsorbed -OH/ carbonate groups
NFigA04 <sup>c</sup>	Co2p	...	...	45294	3.590	8.6	Co in Co <sub>3</sub> O <sub>4</sub>
NFigA04	Co2p <sub>3/2</sub>	780.9	1.8	...	...	...	Co in Co <sub>3</sub> O <sub>4</sub>
NFigA04	Co2p <sub>1/2</sub>	796.6	1.8	...	...	...	Co in Co <sub>3</sub> O <sub>4</sub>
NFigA05 <sup>d</sup>	Sn3d	...	...	178484	...	15.6	Sn in SnO <sub>2</sub>
NFigA05	Sn3d <sub>5/2</sub>	486.7	1.4	108215	4.725	...	Sn in SnO <sub>2</sub>
NFigA05	Sn3d <sub>3/2</sub>	495.2	1.4	70269	...	...	Sn in SnO <sub>2</sub>
NFigB02 <sup>a</sup>	C1s	284.8	1.8	8834.6	0.296	21.7	Adventitious surface contamination
NFigB02 <sup>a</sup>	C1s	286.5	1.9	1125.3	0.296	2.8	C-O species from precursor residuals
NFigB02 <sup>a</sup>	C1s	288.5	2.1	1039.0	0.296	2.6	Adsorbed carbonates
NFigB03 <sup>b</sup>	O1s	530.0	1.7	28863.1	0.711	29.5	Lattice oxygen in Co <sub>3</sub> O <sub>4</sub> and Fe <sub>2</sub> O <sub>3</sub>
NFigB03 <sup>b</sup>	O1s	531.4	2.2	18065.9	0.711	18.5	Surface adsorbed -OH/ carbonate groups
NFigB04 <sup>c</sup>	Co2p	...	...	31137	3.590	6.4	Co in Co <sub>3</sub> O <sub>4</sub>
NFigB04	Co2p <sub>3/2</sub>	780.7	2.1	...	...	...	Co in Co <sub>3</sub> O <sub>4</sub>
NFigB04	Co2p <sub>1/2</sub>	796.3	2.1	...	...	...	Co in Co <sub>3</sub> O <sub>4</sub>
NFigB05 <sup>e</sup>	Fe2p	...	...	73708	2.957	18.5	Fe in Fe <sub>2</sub> O <sub>3</sub>
NFigB05	Fe2p <sub>3/2</sub>	711.0	3.5	...	...	...	Fe in Fe <sub>2</sub> O <sub>3</sub>
NFigB05	Fe2p <sub>1/2</sub>	724.4	3.7	...	...	...	Fe in Fe <sub>2</sub> O <sub>3</sub>

<sup>a</sup> The sensitivity factor is referred to the whole C1s signal.

<sup>b</sup> The sensitivity factor is referred to the whole O1s signal.

<sup>c</sup> The sensitivity factor, peak area, and concentration are referred to the whole Co2p signal.

<sup>d</sup> Tin atomic percentage was evaluated basing on the area and sensitivity factor for the Sn3d<sub>5/2</sub> component reported in the next line.

<sup>e</sup> The sensitivity factor, peak area, and concentration are referred to the whole Fe2p signal.

**Footnote to Spectra NFigA01 and NFigB01:** Wide-scan spectra confirmed the functionalization of Co<sub>3</sub>O<sub>4</sub> with SnO<sub>2</sub> and Fe<sub>2</sub>O<sub>3</sub>, with adventitious carbon as the only impurity. The surface presence of cobalt even after tin and iron oxide deposition was traced back to Co<sub>3</sub>O<sub>4</sub> coverage by very thin SnO<sub>2</sub> and Fe<sub>2</sub>O<sub>3</sub> overlayers.

**Footnote to Spectra NFigA02 and NFigB02:** For both specimens, the C1s peak could be fitted by means of three components, evidencing the presence of C species in different chemical environments. The most intense band, centered at 284.8 eV, was ascribed to adventitious contamination due to atmospheric exposure. A second component located at a mean BE of 286.4 was related to surface C-O moieties from precursor residuals, whereas the contribution at 288.5 eV was ascribed to adsorbed carbonates (Refs. 29-31). The C1s signal could be reduced to noise level after 5 min Ar<sup>+</sup> erosion, revealing a good purity of the target samples.

**Footnote to Spectra NFigA03 and NFigB03:** Two bands contributed to the O1s signal. The main component at BE ≈ 530.0 eV was attributed to lattice O, whereas the second one at BE = 531.4 eV was due to surface carbonates (Refs. 30, 31) and to -OH groups chemisorbed on oxygen defects (Refs. 5, 6, 8, 25, 32-34), which are reported to have a beneficial impact on material (photo)catalytic performances (Refs. 3, 6, 10, 11, 13, 18).

**Footnote to Spectra NFigA04 and NFigB04:** The Co2p peak shape and the absence of intense *shake-up* satellites, indicated the occurrence of Co<sub>3</sub>O<sub>4</sub> as predominant phase (Refs. 2, 9, 25, 29, 33-35), in agreement with XRD results. The Co2p<sub>3/2</sub> BE was 780.9 and 780.7 eV for Co<sub>3</sub>O<sub>4</sub>-SnO<sub>2</sub> (NFigA04) and Co<sub>3</sub>O<sub>4</sub>-Fe<sub>2</sub>O<sub>3</sub> (NFigB04) respectively, slightly higher values than those reported in the literature for bare Co<sub>3</sub>O<sub>4</sub> (Refs. 1, 2, 30, 32, 36). This phenomenon was related to electronic interactions between the single oxides (Ref. 37), considering that, at the Co<sub>3</sub>O<sub>4</sub>/SnO<sub>2</sub> (Fe<sub>2</sub>O<sub>3</sub>) interface, an electron transfer occurs from Co<sub>3</sub>O<sub>4</sub> to SnO<sub>2</sub> (Fe<sub>2</sub>O<sub>3</sub>) (see also comments to spectra NFigA05 and NFigB05). The presence of weak Co2p *shake-up* satellites for Co<sub>3</sub>O<sub>4</sub>-Fe<sub>2</sub>O<sub>3</sub> (NFigB04) may suggest the possible presence of CoO as a minority system component (Refs. 29, 35, 38), which may be undetectable by XRD analyses.

**Footnote to Spectra NFigA05 and NFigB05:** The Sn3d [BE(Sn3d<sub>5/2</sub>) = 486.7 eV] and Fe2p [BE(Fe2p<sub>3/2</sub>) = 711.0] peak position were slightly lower than previous literature data for SnO<sub>2</sub> (Refs. 9, 11, 29, 39) and Fe<sub>2</sub>O<sub>3</sub> (Refs. 4, 14, 17, 23, 24, 36), respectively, supporting the above indicated electron transfer process (see comments to spectra NFigA04 and NFigB04).

The average Sn/Co and Fe/Co atomic ratios were 1.8 and 2.9, respectively.

**ANALYZER CALIBRATION TABLE**

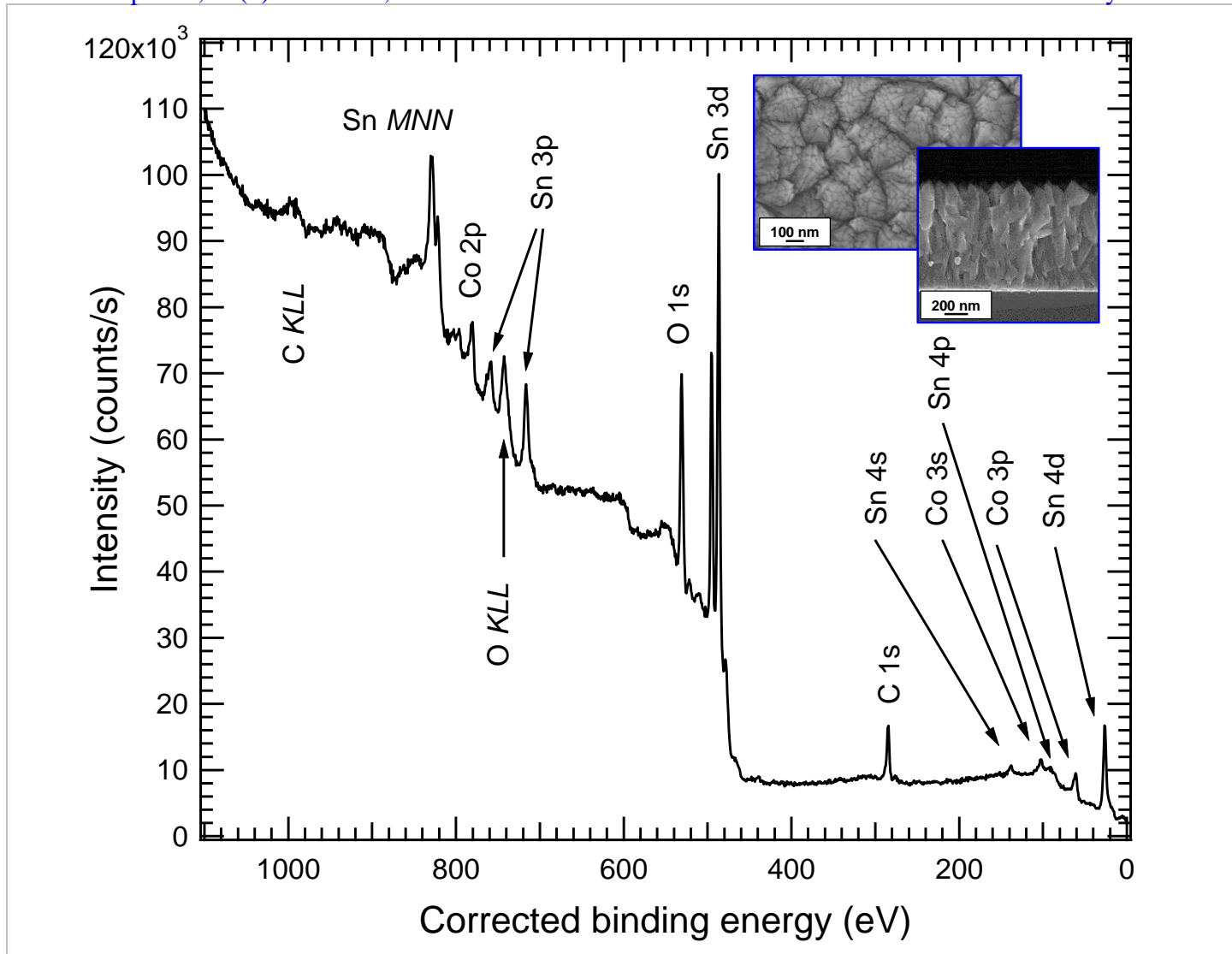
Spectrum ID #	Element/ Transition	Peak Energy (eV)	Peak Width FWHM (eV)	Peak Area (eV x cts/s)	Sensitivity Factor	Concentration (at. %)	Peak Assignment
figCalib01 <sup>a</sup>	Au4f <sub>7/2</sub>	84.0	1.4	186403	...	...	Au(0)
figCalib02 <sup>a</sup>	Cu2p <sub>3/2</sub>	932.7	1.6	86973	...	...	Cu(0)

<sup>a</sup> The peak was acquired after Ar<sup>+</sup> erosion.

**GUIDE TO FIGURES**

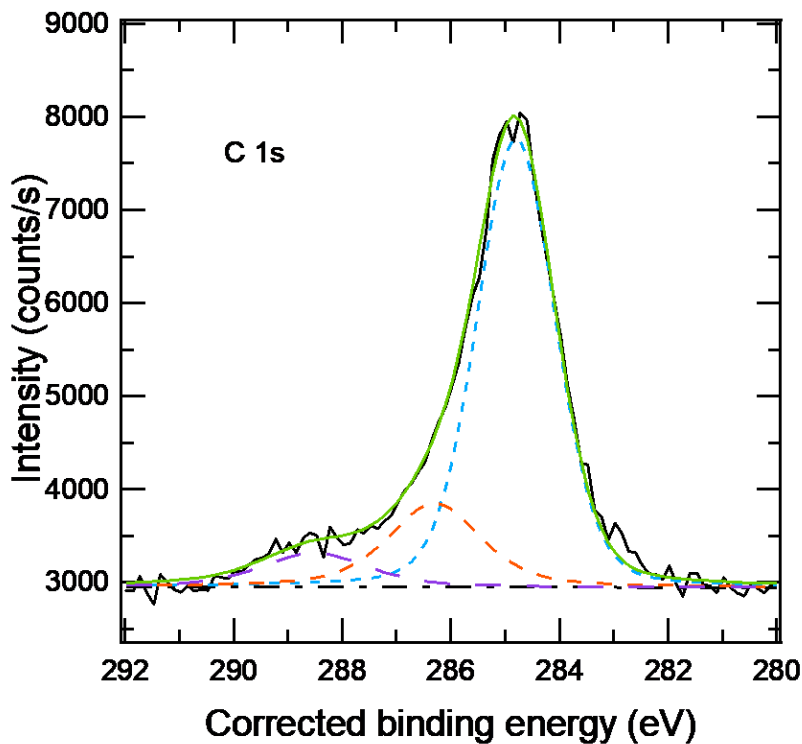
Spectrum (Accession) #	Spectral Region	Voltage Shift*	Multiplier	Baseline	Comment #
NFigA01	Survey	0	1	0	...
NFigA02	C 1s	0	1	0	...
NFigA03	O 1s	0	1	0	...
NFigA04	Co2p	0	1	0	...
NFigA05	Sn3d	0	1	0	...
NFigB01	Survey	0	1	0	...
NFigB02	C 1s	0	1	0	...
NFigB03	O 1s	0	1	0	...
NFigB04	Co2p	0	1	0	...
NFigB05	Fe2p	0	1	0	...

\* Voltage shift of the archived (as measured) spectrum relative to the printed figure. The figure reflects the recommended energy scale correction due to a calibration correction, sample charging, flood gun, or other phenomenon.



Publish in *Surface Science Spectra*: Yes X No

Accession #	NFigA01
Host Material	Co <sub>3</sub> O <sub>4</sub> -SnO <sub>2</sub>
Technique	XPS
Spectral Region	survey
Instrument	Perkin-Elmer Physical Electronics, Inc. 5600ci
Excitation Source	Mg Ka
Source Energy	1253.6 eV
Source Strength	250 W
Source Size	>25 mm x >25 mm
Analyzer Type	spherical sector analyzer
Incident Angle	9°
Emission Angle	45°
Analyzer Pass Energy	187.85 eV
Analyzer Resolution	1.9 eV
Total Signal Accumulation Time	385.2 s
Total Elapsed Time	423.7 s
Number of Scans	14
Effective Detector Width	1.9 eV



Publish in SSS: Yes  No

■ Accession #: NFigA02

■ Host Material: Co<sub>3</sub>O<sub>4</sub>-SnO<sub>2</sub>

■ Technique: XPS

■ Spectral Region: C 1s

Instrument: Perkin-Elmer Physical Electronics, Inc. 5600ci

Excitation Source: Mg Ka

Source Energy: 1253.6 eV

Source Strength: 250 W

Source Size: >25 mm x >25 mm

Analyzer Type: spherical sector

Incident Angle: 9 °

Emission Angle: 45 °

Analyzer Pass Energy 58.7 eV

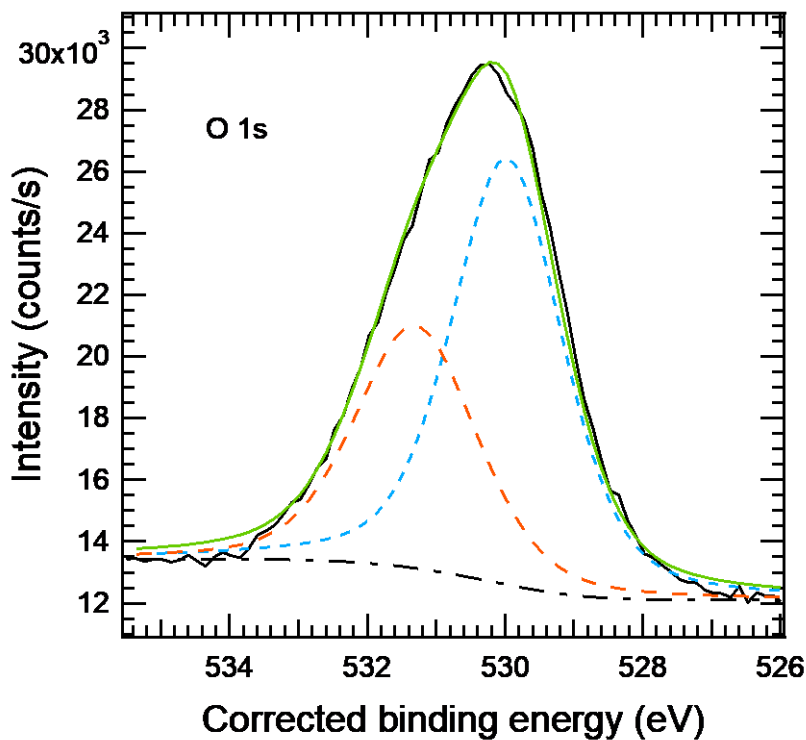
Analyzer Resolution: 0.6 eV

Total Signal Accumulation Time: 67.8 s

Total Elapsed Time: 74.6 s

Number of Scans: 12

Effective Detector Width: 0.6 eV



Publish in SSS: Yes  No

■ Accession #: NFigA03

■ Host Material: Co<sub>3</sub>O<sub>4</sub>-SnO<sub>2</sub>

■ Technique: XPS

■ Spectral Region: O 1s

Instrument: Perkin-Elmer Physical Electronics, Inc. 5600ci

Excitation Source: Mg Ka

Source Energy: 1253.6 eV

Source Strength: 250 W

Source Size: >25 mm x >25 mm

Analyzer Type: spherical sector

Incident Angle: 9 °

Emission Angle: 45 °

Analyzer Pass Energy 58.7 eV

Analyzer Resolution: 0.6 eV

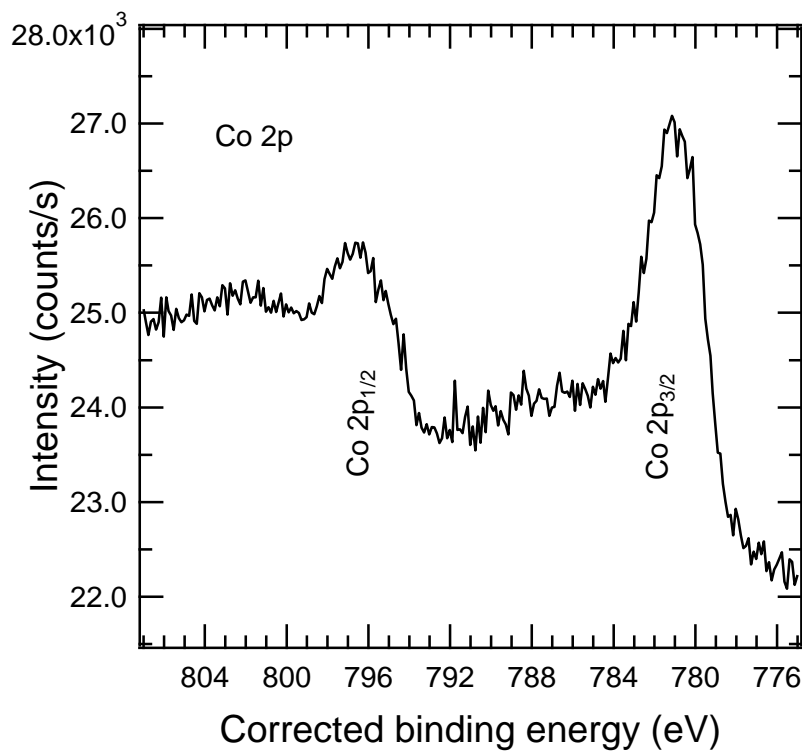
Total Signal Accumulation Time: 90.4 s

Total Elapsed Time: 99.4 s

Number of Scans: 16

Effective Detector Width: 0.6 eV





**Publish in SSS: Yes X No**

■ **Accession #:** NFigA04.

■ **Host Material:** Co<sub>3</sub>O<sub>4</sub>-SnO<sub>2</sub>

■ **Technique:** XPS

■ **Spectral Region:** Co 2p

Instrument: Perkin-Elmer Physical  
Electronics, Inc. 5600ci

Excitation Source: Mg Ka

Source Energy: 1253.6 eV

Source Strength: 250 W

Source Size: >25 mm x >25 mm

Analyzer Type: spherical sector

Incident Angle: 9 °

Emission Angle: 45 °

Analyzer Pass Energy 58.7 eV

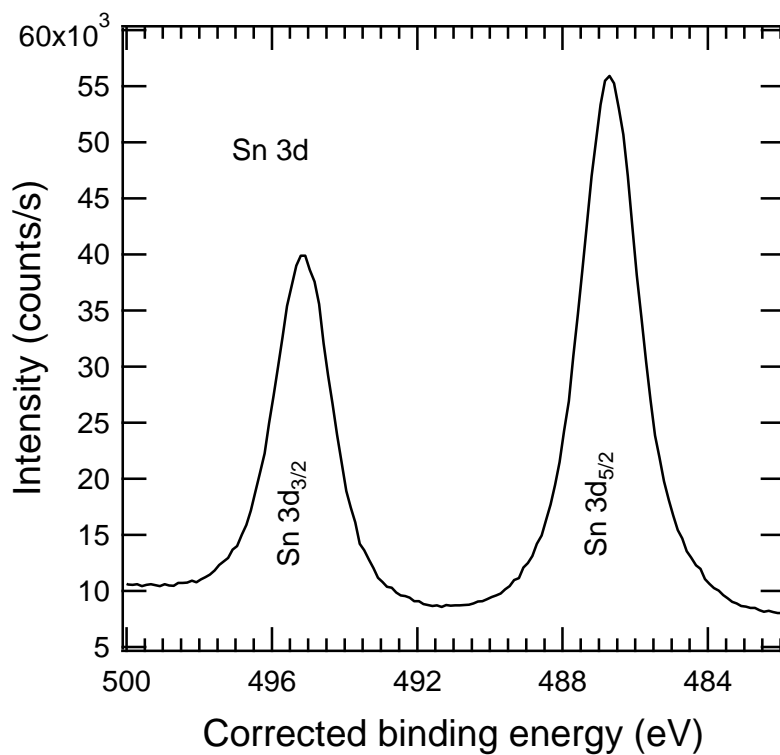
Analyzer Resolution: 0.6 eV

Total Signal Accumulation Time: 541.5  
s

Total Elapsed Time: 595.6 s

Number of Scans: 30

Effective Detector Width: 0.6 eV



**Publish in SSS: Yes X No**

■ **Accession #:** NFigA05.

■ **Host Material:** Co<sub>3</sub>O<sub>4</sub>-SnO<sub>2</sub>

■ **Technique:** XPS

■ **Spectral Region:** Sn 3d

Instrument: Perkin-Elmer Physical  
Electronics, Inc. 5600ci

Excitation Source: Mg Ka

Source Energy: 1253.6 eV

Source Strength: 250 W

Source Size: >25 mm x >25 mm

Analyzer Type: spherical sector

Incident Angle: 9 °

Emission Angle: 45 °

Analyzer Pass Energy 58.7 eV

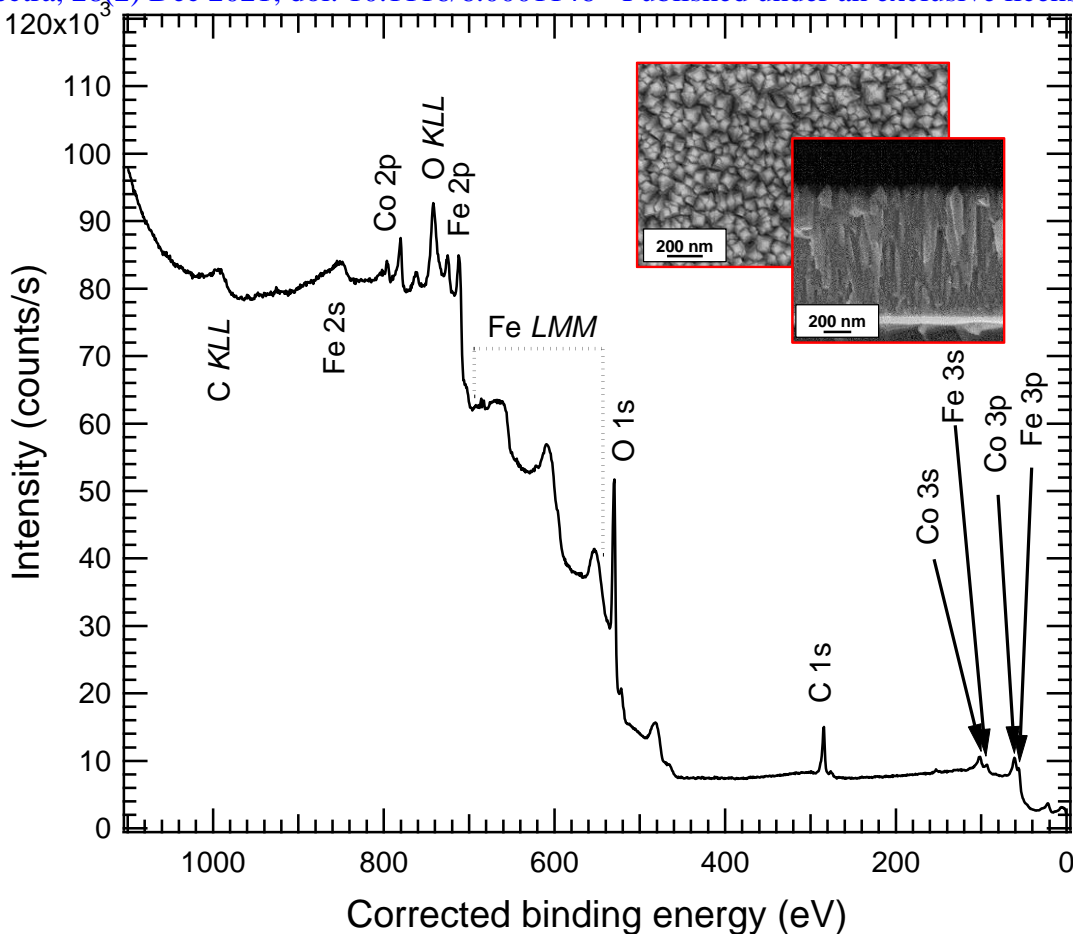
Analyzer Resolution: 0.6 eV

Total Signal Accumulation Time: 180.9  
s

Total Elapsed Time: 199.0 s

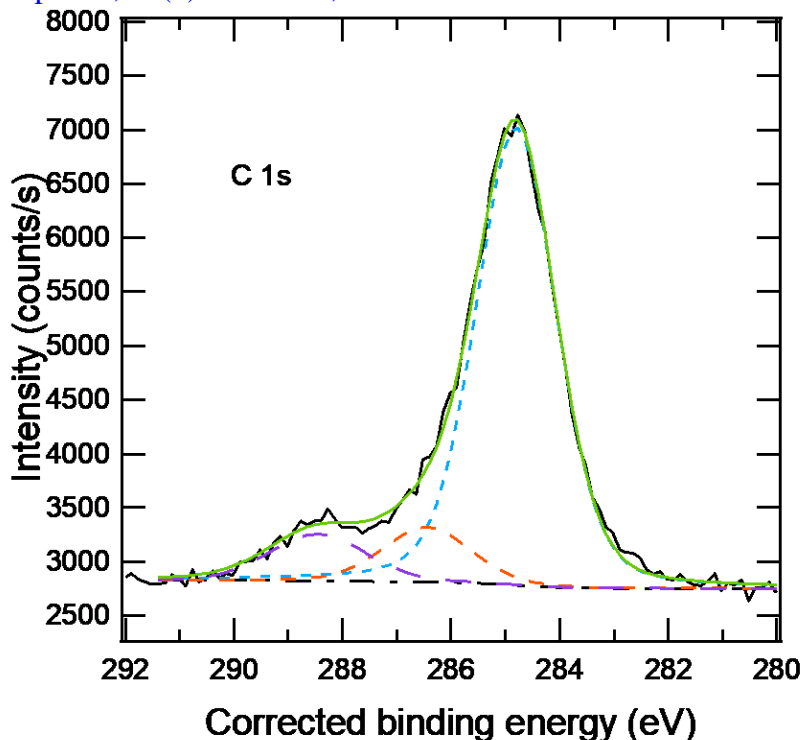
Number of Scans: 18

Effective Detector Width: 0.6 eV



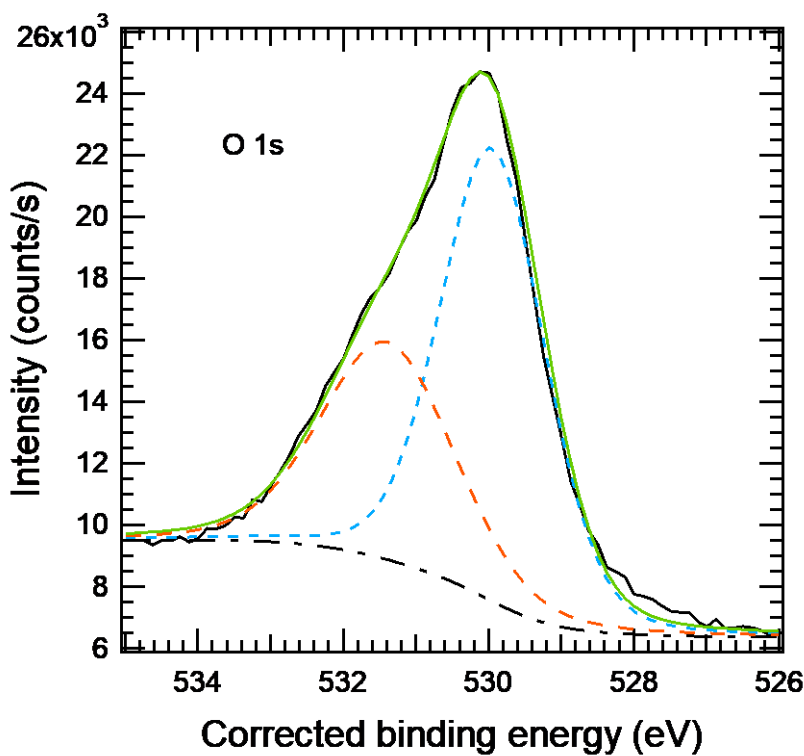
Publish in *Surface Science Spectra*: Yes  No

Accession #	NFigB01
Host Material	Co <sub>3</sub> O <sub>4</sub> -Fe <sub>2</sub> O <sub>3</sub>
Technique	XPS
Spectral Region	survey
Instrument	Perkin-Elmer Physical Electronics, Inc. 5600ci
Excitation Source	Mg Ka
Source Energy	1253.6 eV
Source Strength	250 W
Source Size	>25 mm x >25 mm
Analyzer Type	spherical sector analyzer
Incident Angle	9°
Emission Angle	45°
Analyzer Pass Energy	187.85 eV
Analyzer Resolution	1.9 eV
Total Signal Accumulation Time	2311.8 s
Total Elapsed Time	2543.0 s
Number of Scans	84
Effective Detector Width	1.9 eV



Publish in SSS: Yes  No

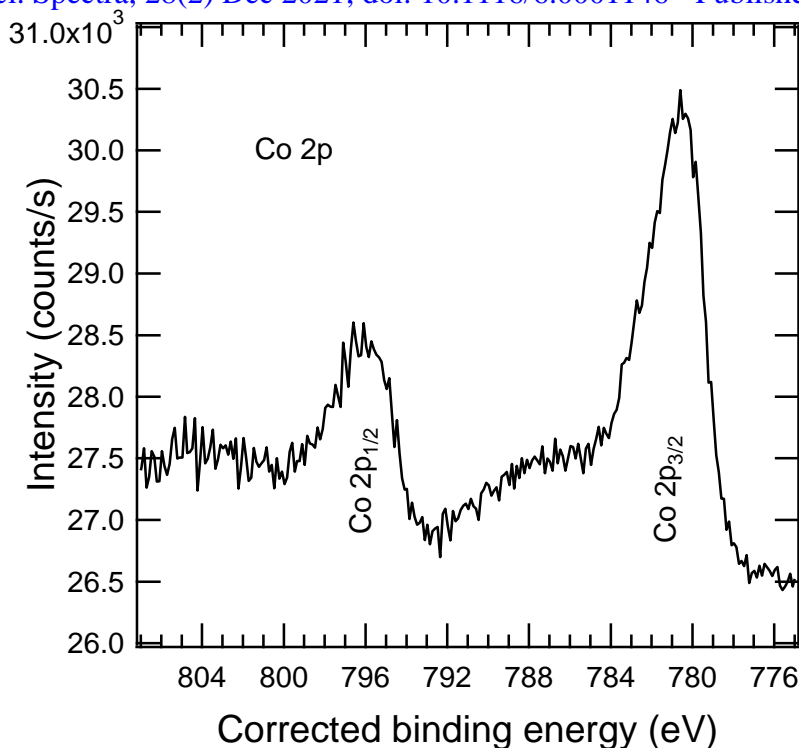
**■ Accession #:** NFigB02.  
**■ Host Material:** Co<sub>3</sub>O<sub>4</sub>-Fe<sub>2</sub>O<sub>3</sub>  
**■ Technique:** XPS  
**■ Spectral Region:** C 1s  
 Instrument: Perkin-Elmer Physical Electronics, Inc. 5600ci  
 Excitation Source: Mg Ka  
 Source Energy: 1253.6 eV  
 Source Strength: 250 W  
 Source Size: >25 mm x >25 mm  
 Analyzer Type: spherical sector  
 Incident Angle: 9 °  
 Emission Angle: 45 °  
 Analyzer Pass Energy 58.7 eV  
 Analyzer Resolution: 0.6 eV  
 Total Signal Accumulation Time: 123.3 s  
 Total Elapsed Time: 135.6 s  
 Number of Scans: 18  
 Effective Detector Width: 0.6 eV



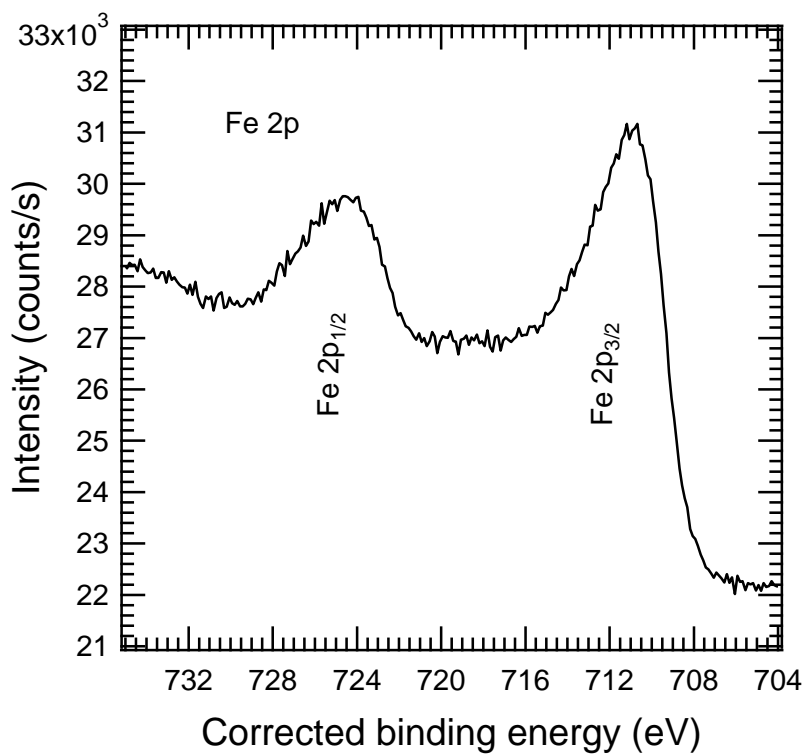
Publish in SSS: Yes  No

**■ Accession #:** NFigB03  
**■ Host Material:** Co<sub>3</sub>O<sub>4</sub>-Fe<sub>2</sub>O<sub>3</sub>  
**■ Technique:** XPS  
**■ Spectral Region:** O 1s  
 Instrument: Perkin-Elmer Physical Electronics, Inc. 5600ci  
 Excitation Source: Mg Ka  
 Source Energy: 1253.6 eV  
 Source Strength: 250 W  
 Source Size: >25 mm x >25 mm  
 Analyzer Type: spherical sector  
 Incident Angle: 9 °  
 Emission Angle: 45 °  
 Analyzer Pass Energy 58.7 eV  
 Analyzer Resolution: 0.6 eV  
 Total Signal Accumulation Time: 116.1 s  
 Total Elapsed Time: 127.7 s  
 Number of Scans: 18  
 Effective Detector Width: 0.6 eV

Publish in SSS: Yes  No



**Accession #:** NFigB04  
**Host Material:** Co<sub>3</sub>O<sub>4</sub>-Fe<sub>2</sub>O<sub>3</sub>  
**Technique:** XPS  
**Spectral Region:** Co 2p  
 Instrument: Perkin-Elmer Physical Electronics, Inc. 5600ci  
 Excitation Source: Mg Ka  
 Source Energy: 1253.6 eV  
 Source Strength: 250 W  
 Source Size: >25 mm x >25 mm  
 Analyzer Type: spherical sector  
 Incident Angle: 9 °  
 Emission Angle: 45 °  
 Analyzer Pass Energy 58.7 eV  
 Analyzer Resolution: 0.6 eV  
 Total Signal Accumulation Time: 1102.75 s  
 Total Elapsed Time: 1213.03 s  
 Number of Scans: 55  
 Effective Detector Width: 0.6 eV



**Publish in SSS: Yes  No**   
**Accession #:** NFigB05  
**Host Material:** Co<sub>3</sub>O<sub>4</sub>-Fe<sub>2</sub>O<sub>3</sub>  
**Technique:** XPS  
**Spectral Region:** Fe 2p  
 Instrument: Perkin-Elmer Physical Electronics, Inc. 5600ci  
 Excitation Source: Mg Ka  
 Source Energy: 1253.6 eV  
 Source Strength: 250 W  
 Source Size: >25 mm x >25 mm  
 Analyzer Type: spherical sector  
 Incident Angle: 9 °  
 Emission Angle: 45 °  
 Analyzer Pass Energy 58.7 eV  
 Analyzer Resolution: 0.6 eV  
 Total Signal Accumulation Time: 882.75 s  
 Total Elapsed Time: 971.03 s  
 Number of Scans: 55  
 Effective Detector Width: 0.6 eV